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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Charles Dennison

Serial No.: 10/652,631

Filed: August 29, 2003

For: Lower Electrode Isolation  
in a Double-Wide Trench  
and Method of Making Same

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Art Unit: 2818

Examiner: Quoc Dinh Hoang

Docket: ITO.0539D1US  
P10144D

Assignee: Intel Corporation

Mail Stop **Amendment**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**REPLY TO PAPER NO. 1204**

Sir:

In response to the office action mailed December 21, 2004, please amend the above-referenced patent application as follows:

Date of Deposit: February 28, 2005

I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

*Cynthia L. Hayden*  
Cynthia L. Hayden